

194

B

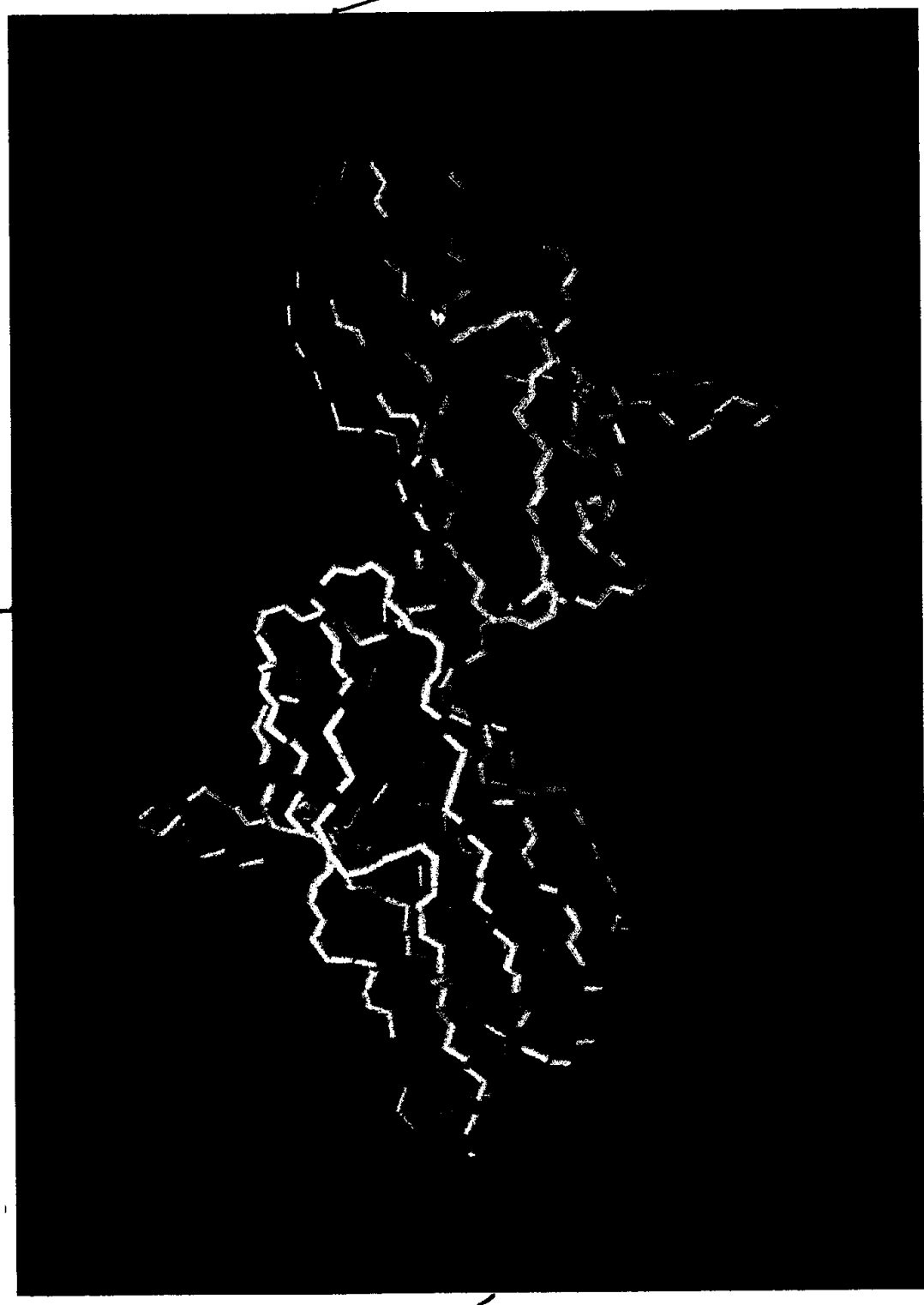


FIG 1

FIG 1 is a photograph of a specimen of a material which has been subjected to a process of etching. The etching process has been carried out in a solution of 10% hydrofluoric acid in water for a period of 24 hours. The etching process has been carried out in a solution of 10% hydrofluoric acid in water for a period of 24 hours. The etching process has been carried out in a solution of 10% hydrofluoric acid in water for a period of 24 hours.

A

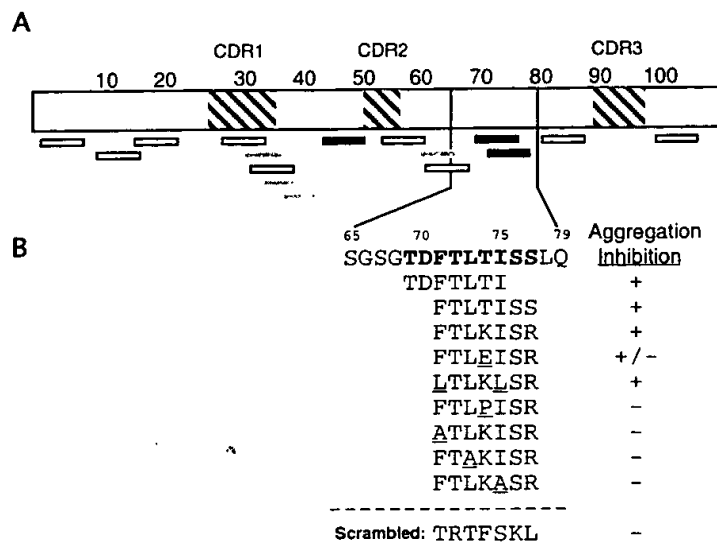


FIG 2

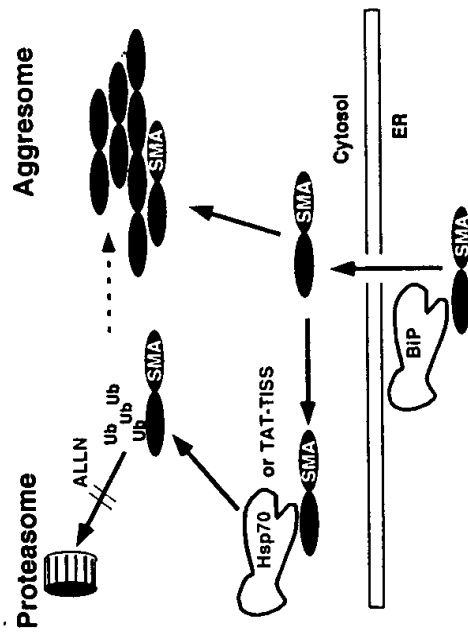


FIG 4

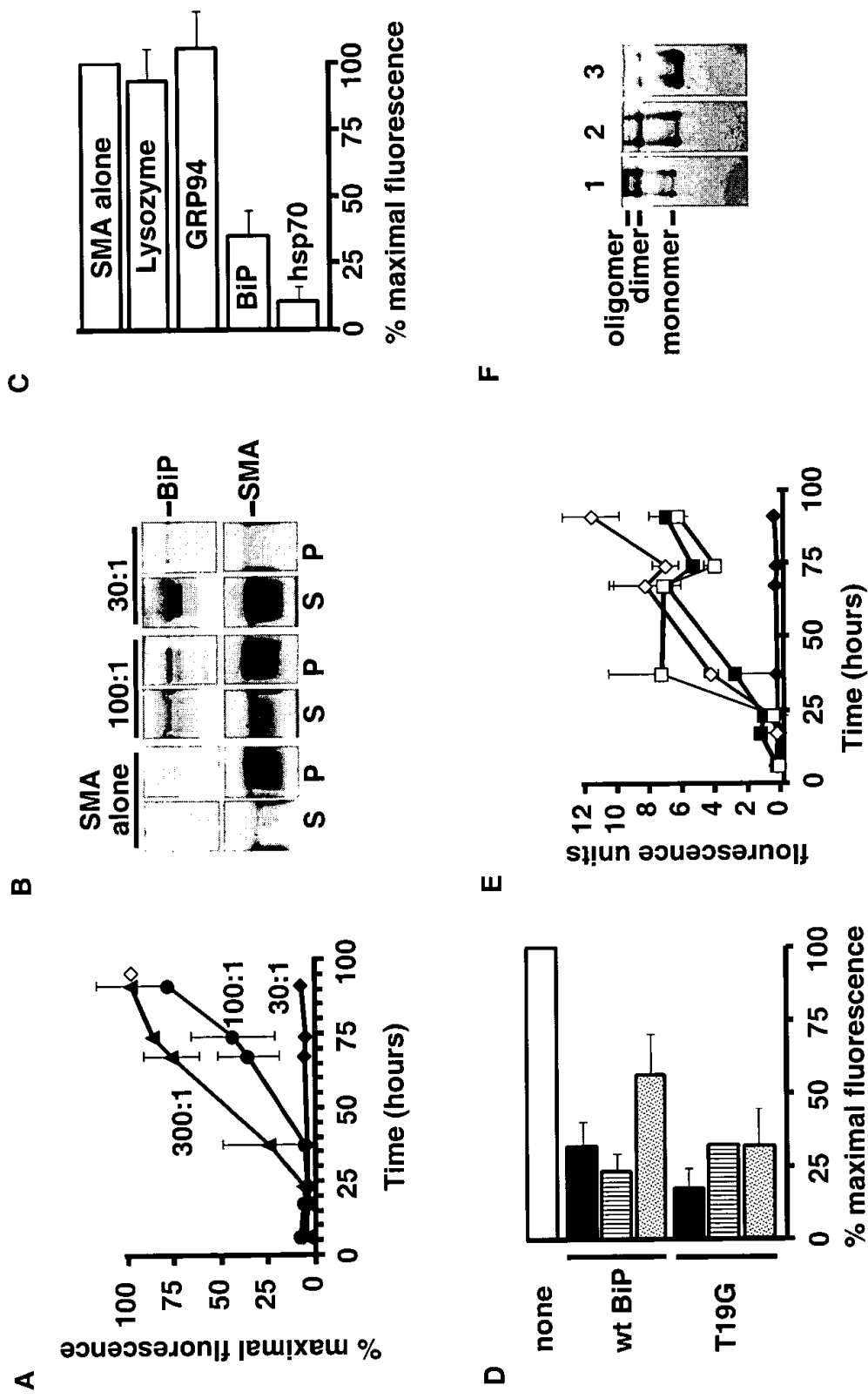


FIG 3